

U.S. Department of Commerce, Patent and Trademark	Atty. Docket No.	Application No.
INFORMATION DISCLOSURE STATEMENT BY APPLICANT	SNDK.267US0	10/086,495
	Applicant(s)	Conf. No.
(Use several sheets if necessary)	Li et al.	2138
	Filing Date	Group
	February 27, 2002	2824

U.S. Patent Documents

*Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
GD	5,991,202	11/23/99	Derhacobian et al.			

U.S. Published Patent Application Documents

*Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate

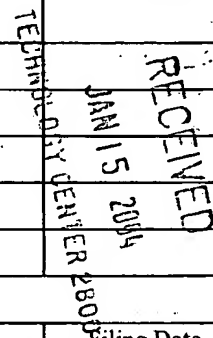
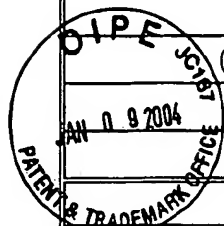
Foreign Patent Documents

							Translation	
	Document	Date	Country	Class	Subclass		Yes	No

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

Examiner SON DINH Date Considered 3/5/04

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.



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2/27/02		2818	

U.S. Patent Documents

*Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
CA	6,072,721	6/6/00	Arase			

U.S. Published Patent Application Documents

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Foreign Patent Documents

							Translation	
	Document	Date	Country	Class	Subclass		Yes	No
CA	EP 1 137 012 A2	9/26/01	EPO					✓

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

CA	Copy of European Search Report dated 6/26/03.

Examiner SAN DINH Date Considered 3/5/14

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